





Basics of STM operation - electronics



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Microscope as a set of mechanical resonators

Most important mechanical parameters:

- resonant frequency,
- mechanical coupling with other parts



Demanded properties of well designed STM:

- high and well separated resonant frequences of particular parts,
- low quality of resonance







Minimal (required) frequency of resonance









Electronic feed-back cotrol

What is right feed-back?

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electronics + mechanical parts act as low-pass filters

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strong (fast reaction) for topographical meas.weak (slow reaction) for current measurementno feed-back for spectroscopy

The gain has to be sufficiently low to avoid change of the negative feed-back into positive feed-back at high frequences.









Microscope at UMCS









Tip size vs atomic structures - scale preserved









Typical false images - blunt tip vs sharp tip



STM images of the same area of Si(111)6x6-Au surface recorded with blunt (left) and sharp (right) tip.







Tip damage during scan



STM image of Si(111)6x6-Au surface. The sample is scanned from bottom to top. Sudden lost of the resolutiuon occurs due to capture by the tip of some particle. 8







Blunt tip - contamination



STM image of the place where a short current pulse of 10V, 0.2 nA to a blunt/contaminated tip was applied.







Example of extremely sharp tip



This STM image shows Si(111)-6x6-Au surface with 7 Pb atoms on it.

The atoms occupy different atomic positions and hence form various orbitals. Three-fold symmetry of the substrate is clearly seen for atoms in the middle.







Thermal drift and histeresis of scanner









Thermal drift and hysteresis of scanner









Fourier filter - noise removing



after

Image







Multiple tip effect

multiple "clones" of Pb islands









Tunneling spectroscopy (STS)



Typical parameters:

- 1. acquisition time at single point (pixel) ~ 300 μ s
- 2. maximal current up to 10 nA
- 3. number of I V pairs for a single curve ~ 100







Spectroscopy - Pb on Si(111)6x6-Au









Spectroscopy I(V)



2 x 32 averaged I(V) and ...

smoothed







Spectroscopy dl/dV



Original curves and ...

smoothed





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Spectroscopy: normalized conductance

$$I \propto \int_{0}^{e^{V}} \rho(E) T(E,V) dE$$
, for small bias: $\longrightarrow dI/dV \propto \rho(r,V) T(V)$

Within WKB approximation, and for free-electron model:



ho(E) – surface density of states of the sample T(E, V) – transmission of barrier at bias Vho(r, V) – density of states at tip center

normalized plot

 $d\ln I/d\ln V = \left(\frac{dI}{dV}\right)/(I/V)$

reduces rapid increase of dI/dV due to barrier transmission vs bias dependance







Spectroscopy: normalized conductance

